



FORM: PTO-14 (REV: 7-80)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	Atty Docket No: 94-0280.03	Serial No: 09/471,460
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (37 CFR 1.98(b)) (use several sheets if necessary)		Applicant: Thomas A. Figura et al.	
		Filing Date: 12/22/99	Group: 2825

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	
cl	AA 6,117,764	09/12/00	Figura et al.	438	623	
cl	AB 5,950,092	09/07/99	Figura et al.	438	399	
	AC					
	AD					
	AE					
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	AH					
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	AL					
	AM					
	AN					
	AO					
	AP					
	AQ					

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes	Translation No
	AR					<input type="checkbox"/>	<input type="checkbox"/>
	AS					<input type="checkbox"/>	<input type="checkbox"/>

Initial

OTHER ART (including author, title, date, pertinent pages, etc.)

cl	AT		Application Serial No. 09/470,650, entitled USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE, filed December 22, 1999; Thomas A. Figura, Kevin Donohoe, and Thomas Dunbar, inventors; attorney docket No. 94-0280.04; Preliminary Amendment filed December 22, 1999; Response to the Office Action dated May 3, 2001, filed May 21, 2001.
cl	AU		Application Serial No. 09/470,651, entitled USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE, filed December 22, 1999; Thomas A. Figura, Kevin Donohoe, and Thomas Dunbar, inventors; attorney docket No. 94-0280.05; Preliminary Amendment filed December 22, 1999; Amendment After the Continued Prosecution Application and Response to the Office Action dated April 13, 2000 filed July 13, 2000; Response to the Office Action dated September 26, 2000 filed October 5, 2000; Amendment and Response to the Office Action dated November 21, 2000, filed May 21, 2001.
Examiner: <i>culowder</i>			Date Considered: <i>6.12.01</i>

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication with applicant.